

AVS 66th International Symposium and Exhibition

Veranstaltung - AVS 66th International Symposium and Exhibition

Titel	AVS 66th International Symposium and Exhibition
Wann	So, 20. Oktober 2019 - Fr, 25. Oktober 2019

Beschreibung

AVS 66th International Symposium and Exhibition

The Symposium and Exhibition addresses cutting-edge issues associated with materials, processing, and interfaces in the research and manufacturing communities. The weeklong Symposium fosters a multidisciplinary environment that cuts across traditional boundaries between disciplines, featuring papers from AVS technical divisions, technology groups, and focus topics on emerging technologies.

Topics are:

applied surface science
biomaterial interfaces
electronic materials and processing
magnetic interfaces
manufacturing science
MEMS/NEMS
nanoscience
thin film
plasma science
surface science
or vacuum technology

Please learn more about this event by following Link:

<https://www.avs.org/Symposium>

Lokalität - Columbus

Standort	Columbus
Ortsname	Columbus
Bundesland	Ohio
Land	US